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*NANONEX DELIVERS ADVANCED NANOIMPRINT TOOL TO
UNIVERSITY OF CALIFORNIA, DAVIS*

Princeton, NJ, September 27, 2006: Nanonex Corporation, the leader in nanoimprint solution and applications with the longest history, announces today a delivery of Nanonex's advanced nanoimprinter, NX-2000 tool to the University of California, Davis. Other known US national labs and universities that have purchased Nanonex nanoimprint tools include Sandia National Lab, National Nanostructure Infrastructure Network's (NNIN) node at the University of California at Santa Barbara (UCSB), the University of Michigan, the University of Maryland, and Princeton Institute for the Science and Technology of Materials (PRISM) at Princeton University. Nanonex also has supplied nanoimprint materials (resists and molds) to over 100 user groups globally.

The Nanonex NX-2000 acquired by UC Davis is a versatile nanoimprint tool for both uv and thermal imprinting, with an Air Cushion Press (ACP™) critical for excellent imprint uniformity and yield over large area; and with a Smart Sample Holder for flexible imprinting of the molds and substrates having arbitrary shape and geometry (up to 4" diameter).

John Pong, Sales Director at Nanonex said that Nanonex is very proud to become the company that has provided the greatest number of nanoimprint advanced tools to the University of California system. The acquisition of the Nanonex NX2000 nanoimprinter enhances the Northern California Nanotechnology Center's ability to meet the research needs of UC Davis faculty as they incorporate nanotechnology into a variety of disciplines.

On the acquisition of the NX-2000 nanoimprint system, "We plan to expand the use of nanoimprint lithography to material, life sciences and traditional micro and nanofabrications in support of teaching and research at UC Davis", said Dr. Frank Yaghmaie, Director of Northern California Nanotechnology Center (NC2) at UC Davis.

About Nanonex Corp.

Nanonex, a pioneer and a leader in nanoimprint, provides a complete line of nanoimprint lithography (NIL) technology solutions including tools, masks, and processes. Nanonex NIL solutions offer sub 10 nm feature resolution, 3D patterning, large area uniformity, accurate overlay alignment, high-throughput, and low cost. Nanonex NIL solutions include all forms of nanoimprinting, such as thermal plastic, uv-curable, thermal curable, and direct imprinting (embossing). Nanonex NIL solutions can meet the needs of a broad spectrum of markets, such as optical devices, displays, data storage, biotech, IC, chemical synthesis, and advanced materials. In the past 18 months, Nanonex has sold the most nanoimprinters in the USA. Visit www.nanonex.com for additional information.